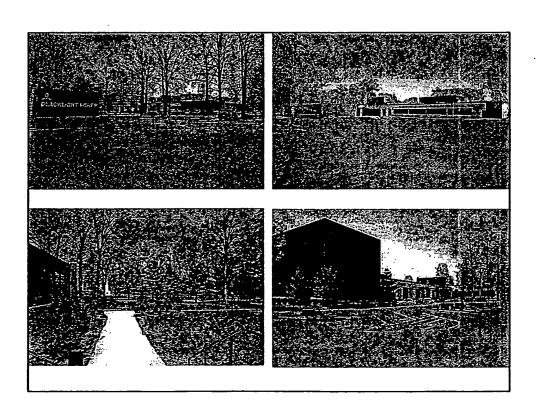


Los Alamos National Laboratory November 25, 2002 Los Alamos, NM

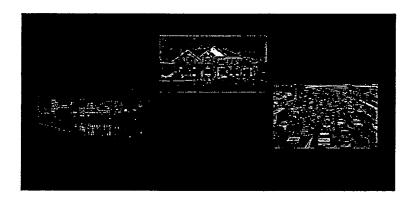
Novel Catalytic Reaction of Hydrogen as a Potential New Energy Source

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Breakthrough in Hydrogen Chemistry with Paradigm-Shifting Applications



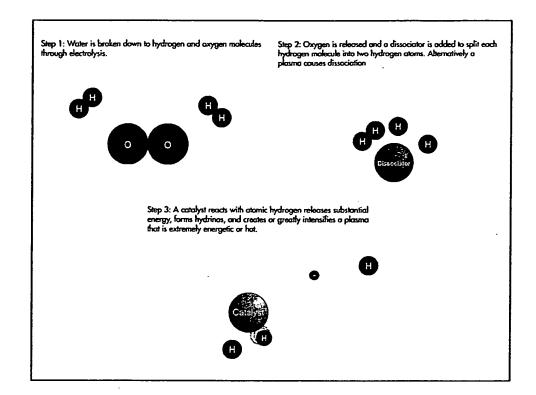
Hydrogen Catalysts

From a solution of a Schrödinger-type wave equation with a nonradiative boundary condition based on Maxwell's equations, atomic hydrogen may undergo a catalytic reaction with certain atomized elements such as potassium, cesium, and strontium atoms or certain gaseous ions such as Ar^+ which singly or multiply ionize at integer multiples of the potential energy of atomic hydrogen, 27.2 eV. The reaction involves a nonradiative energy transfer to form an increased binding energy hydrogen atom called a hydrino having a binding energy of

Binding Energy =
$$\frac{13.6 \, eV}{\left(\frac{1}{p}\right)^2}$$

where p is an integer greater than 1, designated as $H\left[\frac{a_H}{p}\right]$ where a_H is a radius of the hydrogen atom. Hydrinos are predicted to form by reacting an ordinary hydrogen atom with a catalyst having a net enthalpy of reaction of about $m \cdot 27.2 \ eV$, where m is an integer. This catalysis releases energy from the hydrogen atom with a commensurate decrease in size of the hydrogen atom, $r_n = na_H$.

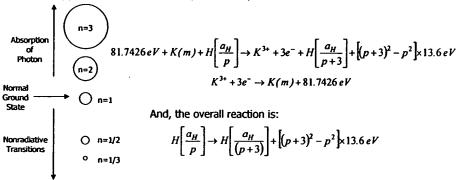
For example, the catalysis of H(n=1) to H(n=1/2) releases 40.8 eV, and the hydrogen radius decreases from a_H to $\frac{1}{2}a_H$.



The Theory Allows Energy to be Extracted from a Hydrogen Atom

Hydrogen electrons are stimulated to a fractional quantum state by the presence of a catalyst with a net enthalpy of reaction of $m \cdot 27.2 \ eV$.

A catalytic system is provided by the ionization of t electrons from an atom each to a continuum energy level such that the sum of the ionization energies of the t electrons is approximately $m \cdot 27.2 \ eV$, where m is an integer. One such catalytic system involves potassium. The first, second, and third ionization energies of potassium are $4.34066 \ eV$, $31.63 \ eV$, $45.806 \ eV$ respectively. The triple ionization (t = 3) reaction of K to K^{3+} , then, has a net enthalpy of reaction of $81.7426 \ eV$, which is equivalent to m = 3.

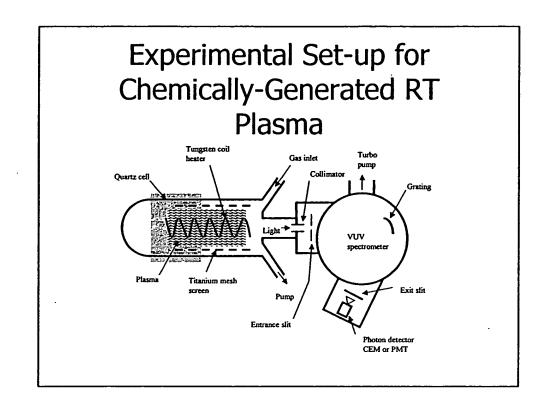


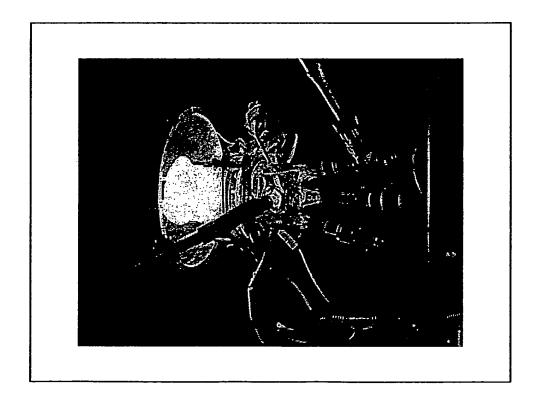
Catalyst Resonant Energy Transfer

- $K(m) + 81.742 \text{ eV} (3 \times 27.2 \text{ eV}) \rightarrow K^{3+} + 3e^{-}$
- $K^+ + K^+ + 27.2 \text{ eV} \rightarrow K^{2+} + K$
- $Rb^+ + 27.28 \text{ eV} \rightarrow Rb^{2+} + e^-$
- $Sr^+ + 54.4 \text{ eV} (2 \times 27.2 \text{ eV}) \rightarrow Sr^{3+} + 2e^-$
- He⁺ + 54.4 eV (2 × 27.2 eV) \rightarrow He²⁺ + e⁻
- $Ar^+ + 27.2 \text{ eV} \rightarrow Ar^{2+} + e^-$
- $O_2 + 54.4 \text{ eV} (2 \times 27.2 \text{ eV}) \rightarrow O^{2+} + O + 2e^{-}$

Based on H Catalyst Reaction

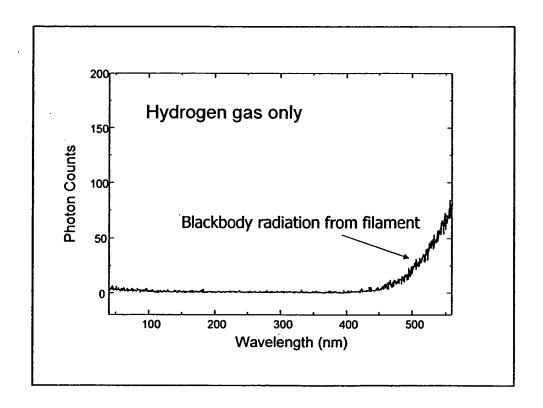
- Chemically Generated or Assisted Plasmas
- Lower-Energy Hydrogen Emission and Isolation
- Catalyst Emission
- Line Broadening
- •Thermal and Optical Power
- •Balmer and Lyman Line Inversions
- •Novel Chemical Compounds
- Novel Processes

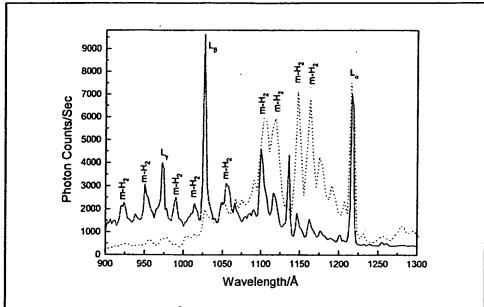


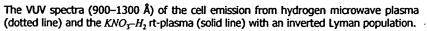


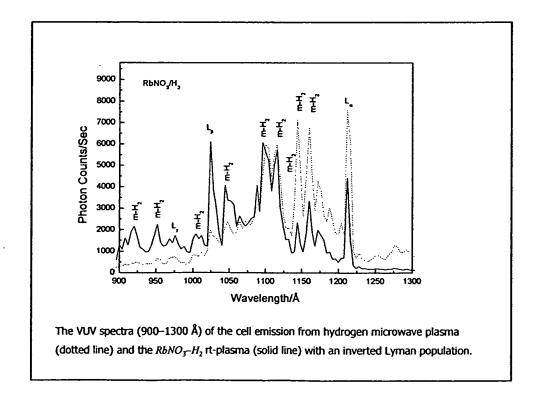
Hydrogen Catalyst Reaction Products

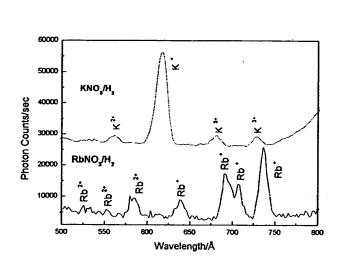
- Plasma
- Light
- Power
- Novel Hydrogen Compounds





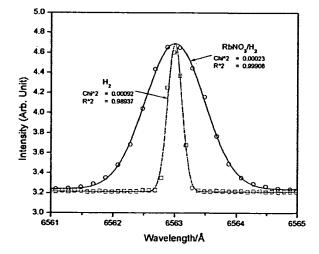




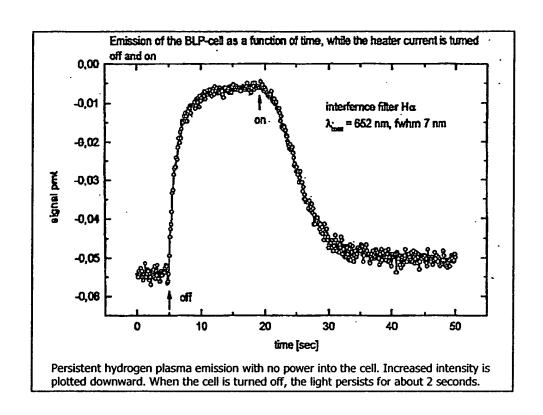


The VUV spectrum (500–800 Å) of the emission of the KNO $_3$ -H $_2$ gas cell (top curve) and the RbNO $_3$ -H $_2$ gas cell (bottom curve). The gas cell comprised a tungsten filament, a titanium dissociator, 300 mTorr hydrogen, and vaporized K $^{+}$ or Rb $^{+}$ from KNO $_3$ or RbNO $_3$, respectively. The emission was recorded with a CEM at a cell temperature of 700 °C. Line emission corresponding to K $^{2+}$ was observed at 553 Å, and K $^{+}$ was observed at 620 Å. K $^{3+}$ was observed at 672 Å and 737 Å. Line emission corresponding to Rb $^{2+}$ was observed at 533 Å, 556 Å, and 581 Å. Rb $^{+}$ was observed at 643 Å, 697 Å, 711 Å, and 741.5 Å.

Balmer α Line Broadening

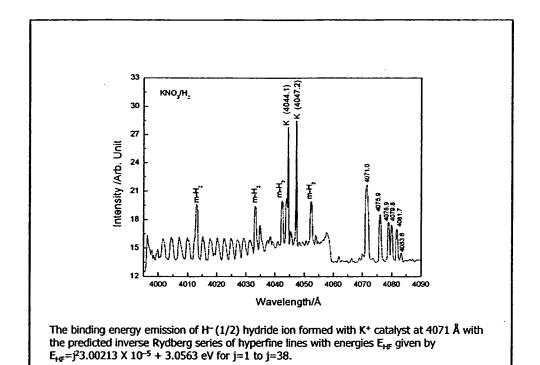


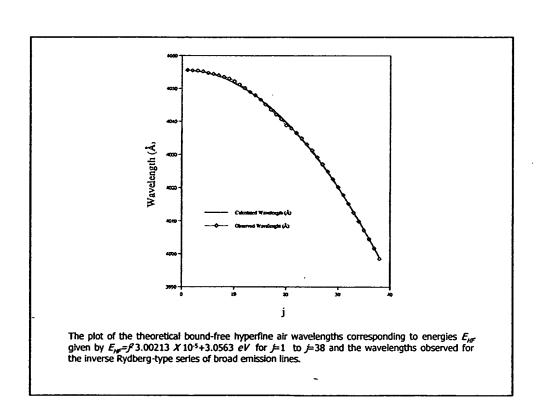
Significant broadening of Balmer α line was observed corresponding to an average hydrogen atom temperature of 10-14 eV compared to that of a microwave hydrogen plasma of 1-2 eV.



Spectral Emission of Fractional-Principal-Quantum-Energy-Level Hydride Ion

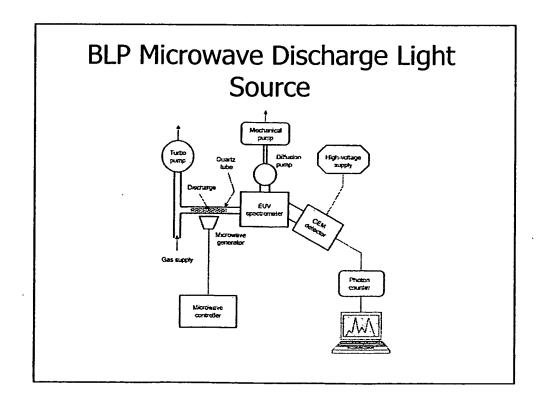
OBSERVED
with a
High Resolution Visible
Spectrometer

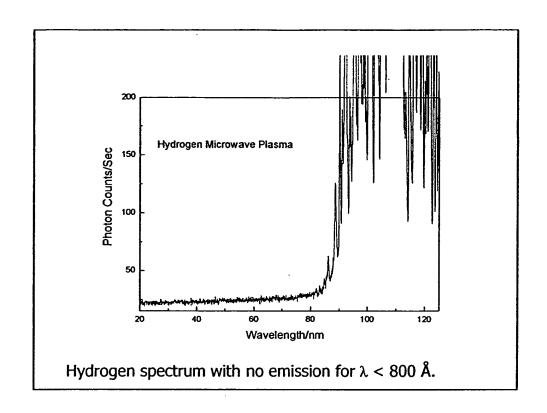


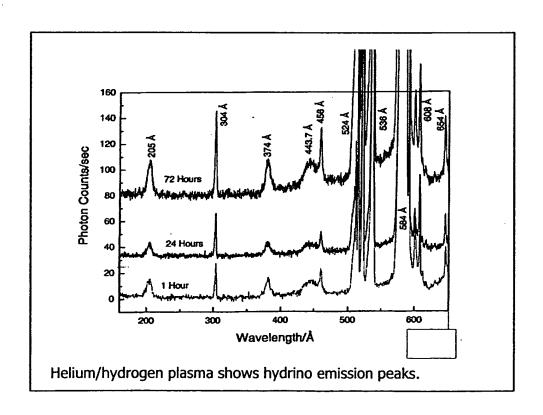


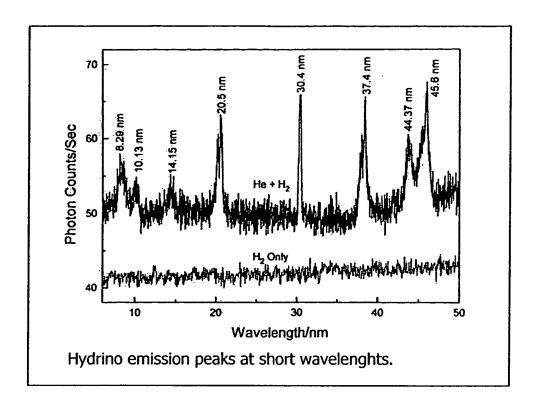
Spectral Emission of Fractional-Principal-Quantum-Energy-Level Atomic Hydrogen

OBSERVED
with a
Normal Incidence EUV
Spectrometer









The Novel Lines can be Explained as Electronic Transitions to Fractional Rydberg States of Atomic Hydrogen

Electronic transitions to fractional Rydberg states given by

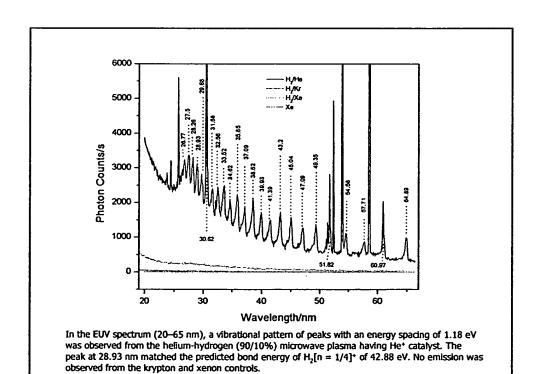
$$E_n = -\frac{e^2}{n^2 8\pi \epsilon_0 a_H} = \frac{13.598 \, eV}{n^2} \qquad n = \frac{1}{2}, \frac{1}{3}, \frac{1}{4}, \dots, \frac{1}{p}$$

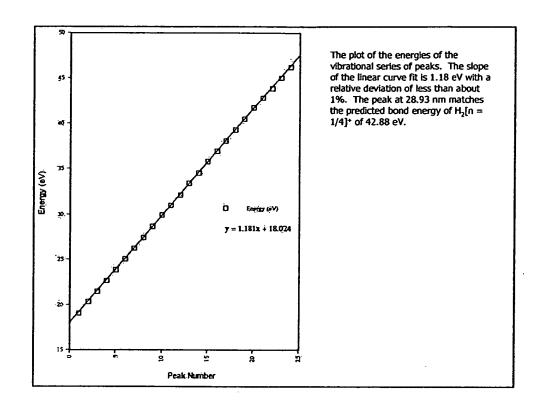
p is an integer catalyzed by the resonant nonradiative transfer of $m\cdot27.2~eV$ would give rise to a series of emission lines of energies $q\cdot13.6~eV$ where q is an integer.

• Novel EUV emission lines with energies of $q \cdot 13.6 \text{ eV}$ where q=1,2,3,4,6,7,8,9, or 11 or these lines inelastically scattered by helium atoms in the excitation of He(1s²) to He(1s¹2p¹) matched hydrogen transitions to electronic energy levels below the "ground" state corresponding to fractional quantum numbers

Vibrational Spectral Emission of Fractional-Principal-Quantum-Energy-Level Hydrogen Molecular Ion

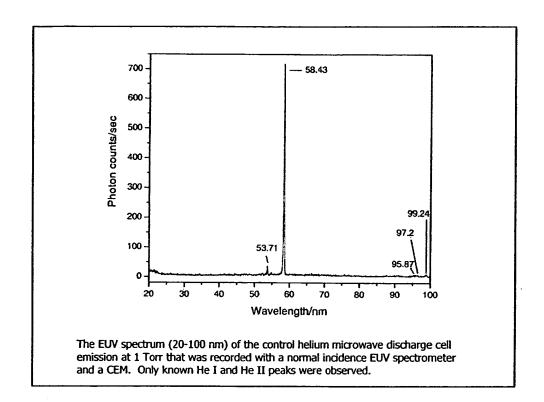
Observed with a 4 ° Grazing Incidence EUV Spectrometer

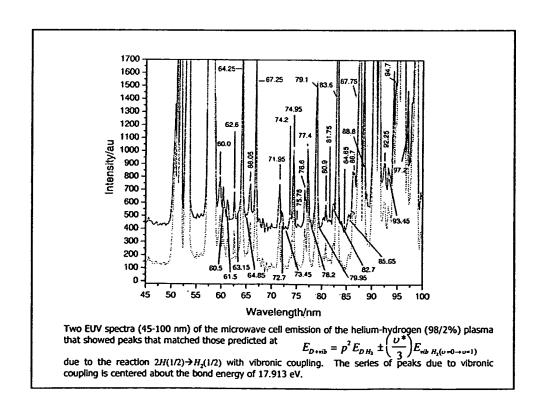


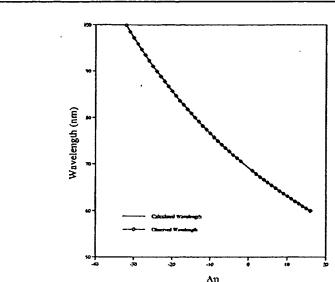


Spectral Emission of Fractional-Principal-Quantum-Energy-Level Molecule

OBSERVED
with a
High Resolution Visible
Spectrometer



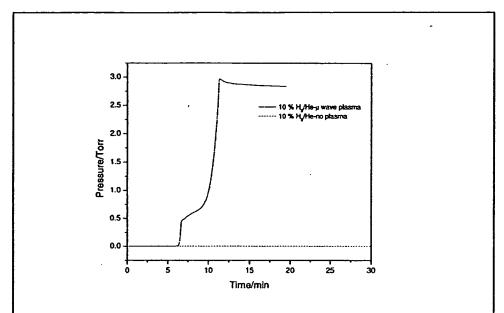




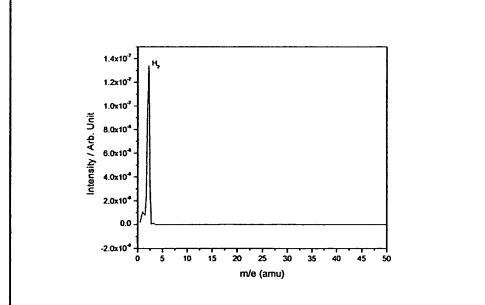
The EUV plasma emission spectra in the region 60 nm to 100 nm matched the predicted emission lines E_{DH2} due to the reaction $2H(1/2) \rightarrow H_2(1/2)$ with vibronic coupling at energies of $E_{D+vib} = p^2 E_{DH_2} \pm \left(\frac{\upsilon^*}{3}\right) E_{vib H_2(\upsilon = 0 \rightarrow \upsilon = 1)}$ (p=2) to longer wavelengths for $\upsilon^* = 2$ to $\upsilon^* = 32$ and to shorter wavelengths for $\upsilon^* = 1$ to $\upsilon^* = 16$ to within the spectrometer resolution of $\pm 0.05\%$.

Isolation of Fractional-Principal-Quantum-Energy-Level Molecular Hydrogen

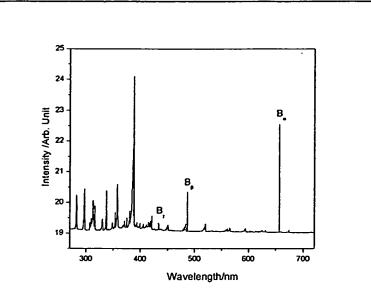
by Condensation at Liquid Nitrogen Temperature



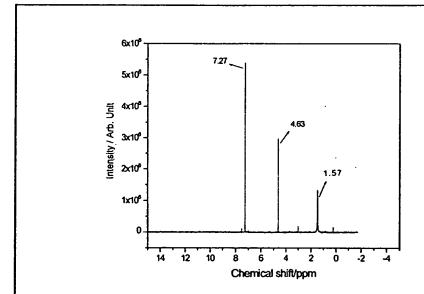
The pressure as a function of time after the liquid nitrogen dewar was removed from the U-tube cryotrap following 2 hours of helium-hydrogen (90/10%) gas flow through the microwave tube and the cryosystem without plasma (dotted) and with a plasma maintained with 60 W forward microwave power and 10 W reflected (solid). A liquid-nitrogen condensable gas product was only observed for the plasma reaction run.



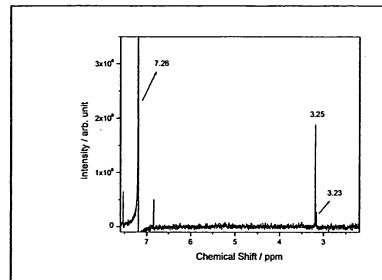
The mass spectrum (m/e = 1 to m/e = 50) of the condensed gas from the helium-hydrogen (90/10%) plasma run for 2 hours. Only hydrogen peaks were observed which identified the liquid-nitrogen-condensable gas as hydrogen.



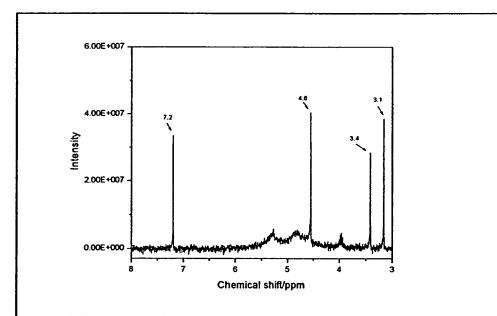
The high resolution (± 0.1 nm) visible optical emission spectrum (275–725 nm) recorded on a microwave discharge plasma of the liquid-nitrogen-condensable helium-hydrogen (90/10%) microwave discharge plasma gas. Strong Balmer α , β , γ and δ lines of atomic hydrogen were observed at 656.28 nm, 486.13 nm, 434.05 nm, and 410.17 nm, respectively, which indicated that the gas contained hydrogen. The spectrum did not match that of any known gas.



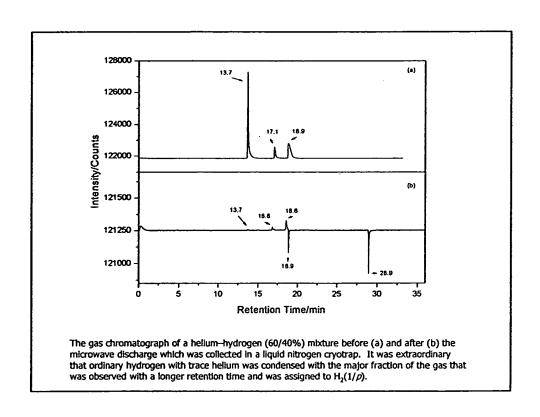
The ^1H NMR spectrum on a sealed sample of ultrahigh purity hydrogen dissolved in CDCl $_3$ relative to external tetramethylsilane (TMS). Singlet peaks, each with small side bands, were observed at 7.27, 4.63, and 1.57 ppm corresponding to CHCl $_3$, H $_2$, and H $_2$ O, respectively.



The ^1H NMR spectrum (2–7.5 ppm) on a sealed sample of liquid-nitrogen- condensable helium-hydrogen plasma gases dissolved in CDCl₃ relative to tetramethylsilane (TMS). A singlet peaks was observed at 7.27 which matched CHCl₃. No H₂ peak was observed at 4.63 ppm. Rather, a novel singlet peak was observed at 3.25 ppm which could not be assigned to a known compound. This upfield peak relative to H₂ was assigned to H₂(1/p). An additional reproducible singlet peak was observed at 3.23 ppm that may be due to an ortho-para effect in H₂(1/p) wherein the relative internuclear separation goes as $1/\rho$.

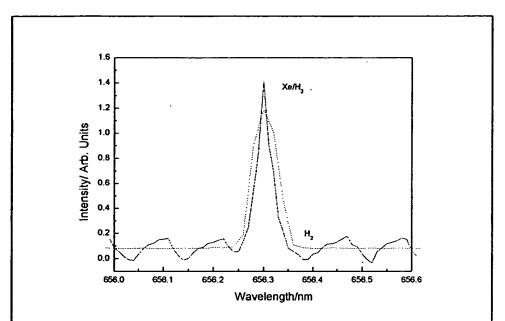


The ¹H NMR spectrum (3–8 ppm) on a sealed sample of liquid-nitrogen- condensable helium-hydrogen plasma gases dissolved in CDCl₃ relative to tetramethylsilane (TMS). A singlet peak was observed at 7.27 which matched CHCl₃, and the H₂ peak was observed at 4.63 ppm. Novel singlet peaks were observed at 3.40 and 3.10 ppm which could not be assigned to a known compound. These upfield peaks relative to H₂ were assigned to H₂(1/ ρ).

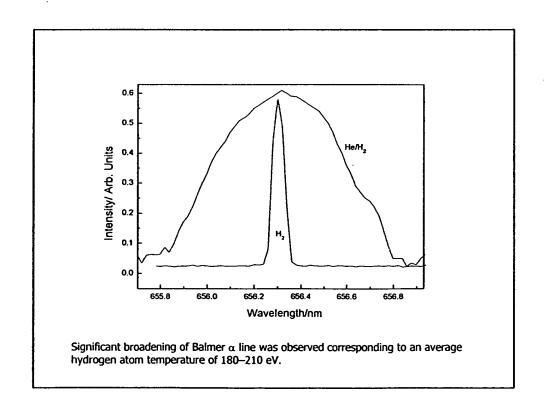


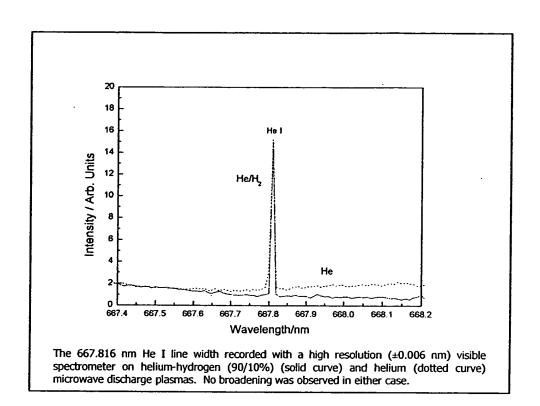
Exothermic Reaction Characterization

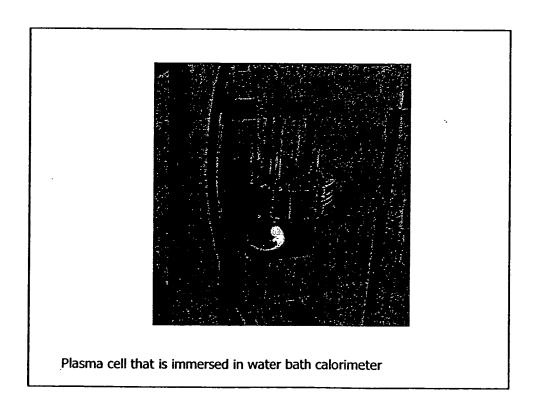
Balmer Line Broadening Calorimetry

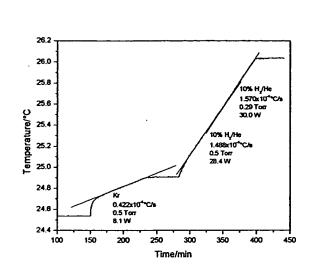


The 656.3 nm Balmer α line width recorded with a high resolution (\pm 0.006 nm) visible spectrometer on a xenon-hydrogen (90/10%) (solid curve) and a hydrogen microwave discharge plasma (dotted curve). No line excessive broadening was observed from either plasma corresponding to an average hydrogen atom temperature of 1–2 eV.





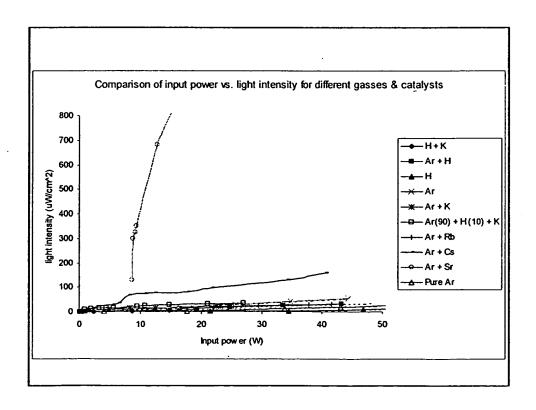




The T(t) water bath response to stirring and then with selected panel meter readings of the constant forward and reflected microwave input power to krypton was recorded. The microwave input power was determined to be 8.1 ± 1 W. A helium-hydrogen (90/10%) mixture was run at identical microwave input power readings as the control, and the excess power was determined to be 21.9 ± 1 W from the T(t) response.



Catalyst Comparison For Optical Power Balance 8,600 Times Less Power Required to Achieve the Same Light Emission with Strontium-Argon Catalyst Present Compared to Control

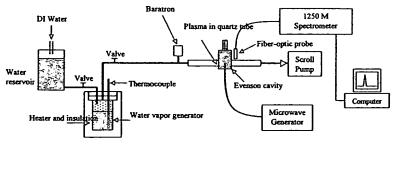


Discharge conditions and comparison of the driving power to achieve a total visible radiant flux of about $1\mu W$ /cm²

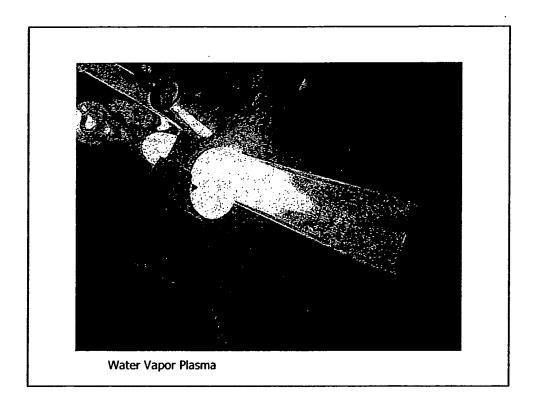
	Τ (℃)	P _{hyd.} (torr)	P _{Ar} (torr)	P _v (torr) ^a	Voltage (V)	Current (mA)	Integ. time (ms)	Detector irradiation (µW/cm²)	Power (W)
Ar+H ₂ +Sr	514	0.3	1.0	0.006	6.56	0.6	204	1.3	0.0039
Ar+H ₂	519	0.295	0.5		224	184	409	1.9	33.5⁵
Ar	520		1.0		190	170	307	1.1	24.70
H ₂ +Sr	664			0.270	2.20	3.86	768	1.17	0.0085
H ₂	664	1.0			224	110	1130	2.08	24.6
H ₂ +Na	335	1.0		0.051	272	124	122	1.85	33.7
H ₂ +Na	516	1.5		5.3	220	68	768	0.40	15.0
H ₂ +Na	664	1.5		63	240	41	768	0.41	9.84
H ₂ +Mg	449	4.0		0.016	153	380	500	1.7	58
H ₂ +Mg	582	4.2		0.6	233	290	500	0.16	68
H ₂ +Mg	654	3.0		2.8	250	400	1000	0.18	100.0
H ₂ +Ba	666	2.0		0.025	138	730	716	0.03	55°
Bkgnd.	664			0.270	0	0	768	0.20	0

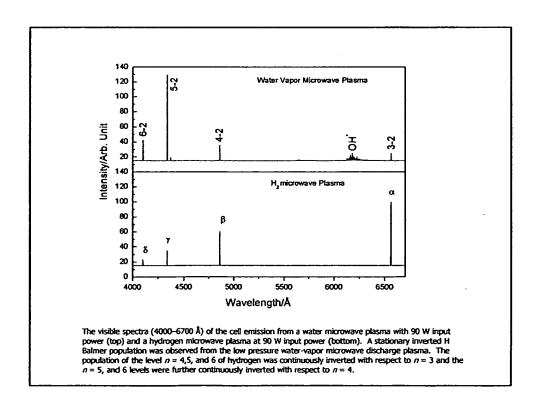
a Calculated.

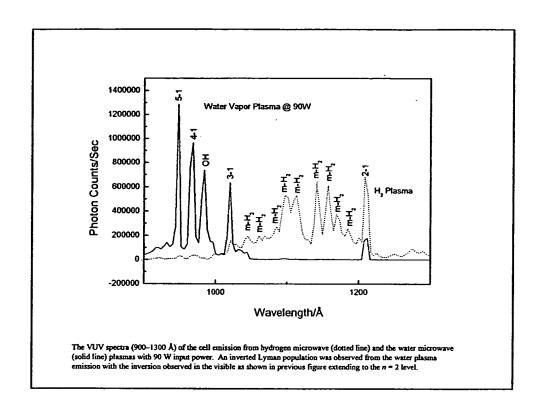
Experimental Set-up for Water Microwave Plasma

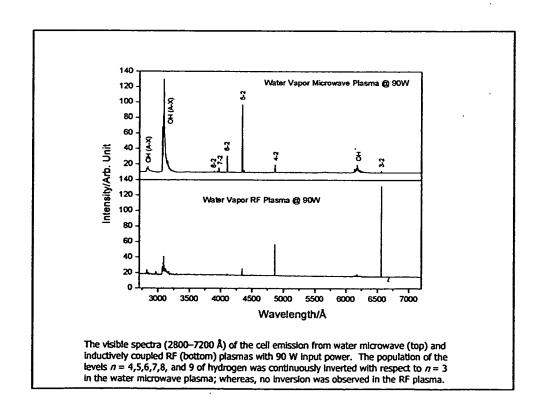


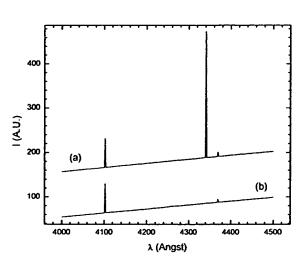
^b Power input differs from volt-amperes due to non-unity power factor.







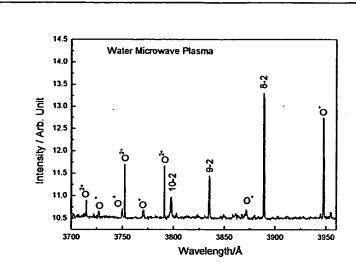




The results of back illumination with a 70 W incandescent lamp where (a) is the sum of the independent lamp and plasma spectra and (b) the spectrum recorded with the lamp and plasma run simultaneously. Background (dark) spectra were subtracted from both traces shown. Spectrum (a) has been shifted upward by 100 A.U. for illustration purposes. The absence of the Balmer $_{\Upsilon}$ 4340 Å line corresponding to the n=5 to n=2 transition indicates that the lamp stimulated the depopulation of the n=5 state to one or more of the n=4 and n=3 states.

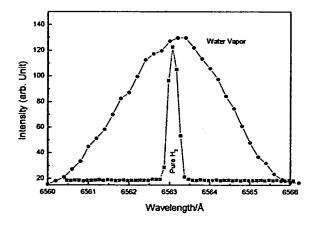
Potential laser transitions of atomic hydrogen in a microwave water-vapor plasma

Wavelength/Å	Spectral	Electronic Transition
	Region	n _{initial} - n _{final}
74,578	IR	6 → 5
40,512	IR	5 → 4
26,252	IR	6 → 4
18,751	IR	4 → 3
12,818	IR	5 → 3
10,938	IR	6 → 3
10,049	IR	7 → 3
6,563	red	3 → 2
4,861	blue	4 → 2
4,340	violet	5 → 2
4,102	violet	6 → 2
3,970	violet	7 → 2
3,889	violet	8 → 2



The visible spectrum (3700–3960 Å) of the cell emission from a water microwave plasma at 90 W input power. The catalysis mechanism was supported by the observation of O^{2+} at 3715.0 Å, 3754.8 Å, and 3791.28 Å. O^{+} was observed at 3727.2 Å, 3749.4 Å, 3771 Å, 3872 Å, and 3946.3 Å. The hydrogen Balmer lines corresponding to the transitions 10–2, 9–2, and 8–2 were also observed.

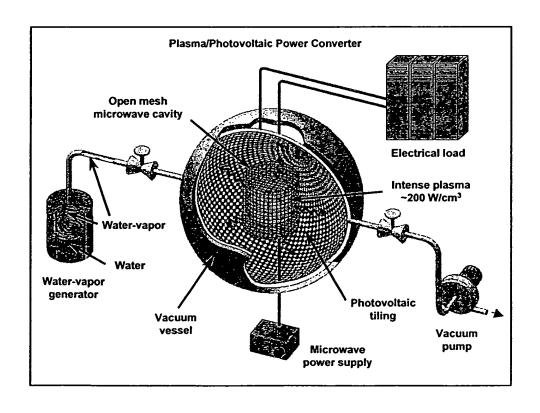
Balmer α-Line Broadening



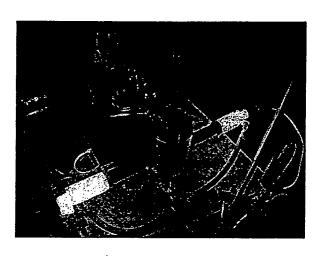
The pumping rate and pumping power calculated from the collisional-radiative model for laser transitions 5–2, 5–3, and 6–2

Laser Transition	Calculated Pumping Rate of Upper Level (10 ¹⁹ cm ³ s ⁻¹)	Calculated Pumping Power $(W \cdot cm^3)$
5-2	8.43	175.3ª
5-3	• • •	2.0.0
6-2	2.12	44.8

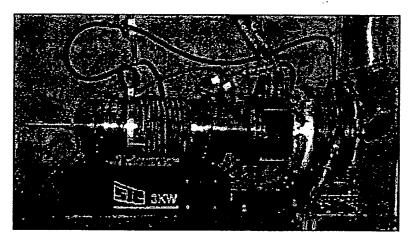
a for 5-2 and 5-3 transitions

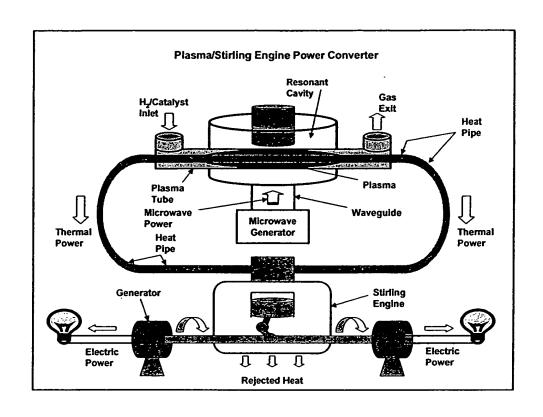


Plasma Power Scale-Up



3 kWe Stirling Engine STC Inc.





Major Components Cost Estimate for Mass-Produced BLP Electric Generator

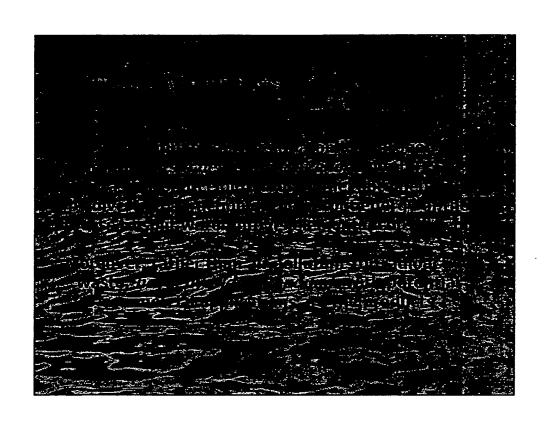
Component Costs (Direct)	Dollars
Photovoltaic Array	25 per kW
Inverter, control, wires	50 per kW
Cooling	5 per kW
Balance of Plant (independent of size)	282

Unit Costs: BLP vs Competitors Technology Average Generating Fuel Mass Power Fuel Installed Fuel **Density** Volumetric Type **Energy Density** Cost Cost Capacity (W/cm³) **Energy** (kWh/kg) (\$/kW) (\$/kW (kW) Density h) (kWh/gal) **BLP Energy** 25 40 23,000 6,000 150 0 Technology PEM Fuel Cell 25 1 9 3,700** 0.065 Internal 100 40 33 12 1,400** 0.044 Combustion Engine Industrial Gas 1000 1 19 12 1,600 0.038 Turbine Natural Gas 100 1 19 12 2,000 0.044 Microturbine Photovoltaic 0.01 10 N/A N/A 8,000 0 Coal 400,000 0.3 N/A 8.3 1,100 0.015 Nudear 600,000 2 N/A N/A 2,200 0.006

Source: DOE, EPRI, ENREN *Watts per square centimeter **Current Cost of stationary distributed generation equipment

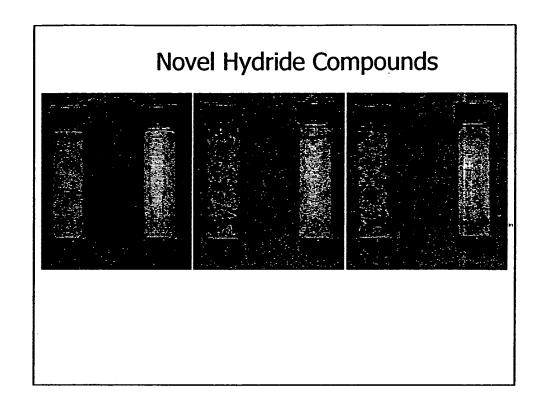
BLP MicroGen Advantages

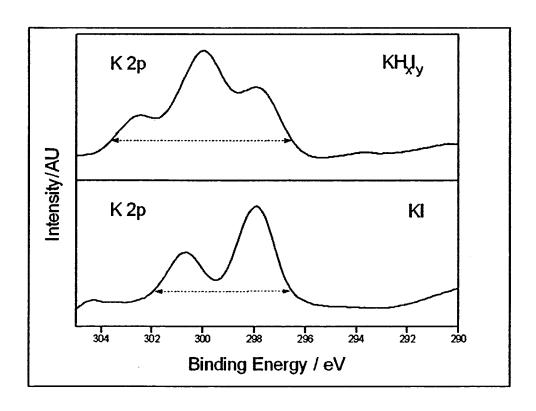
- No Fuel Costs
- Solid State Device
- Cost Competitive (Lower Capital and O&M Costs)
- No Fuel Handling Issues / Pollution
- Load Following
- No Grid Connection (Gas or Electric for Fuel or Load Leveling)
- Valuable chemical products

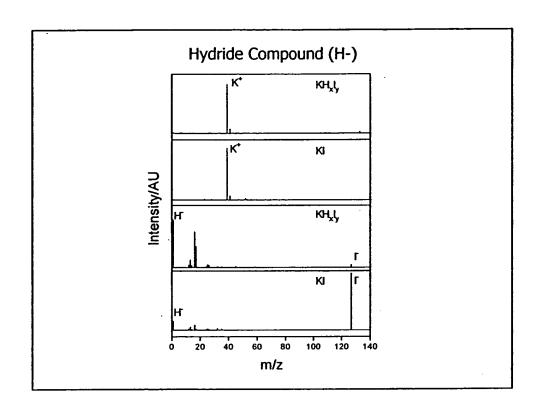




Novel Hydride Compounds



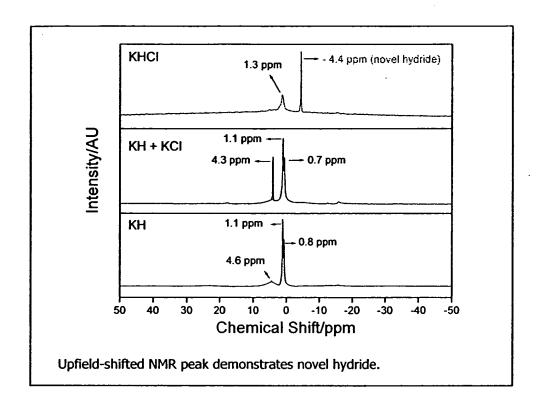


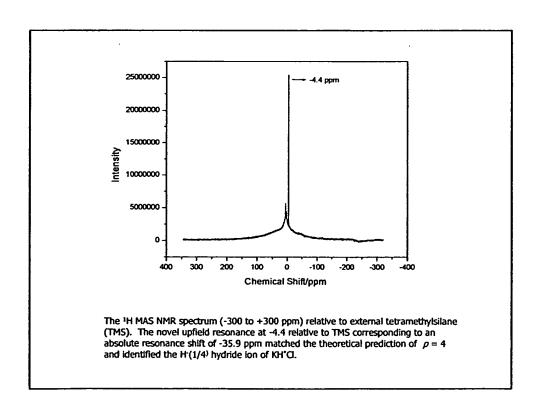


Solid-State MAS ¹H-NMR

- Chemical environment of hydrogen
- Unusual upfield shifts relative to normal hydride

(the electron is closer to the nucleus in a smaller hydride ion called a hydrino hydride ion)



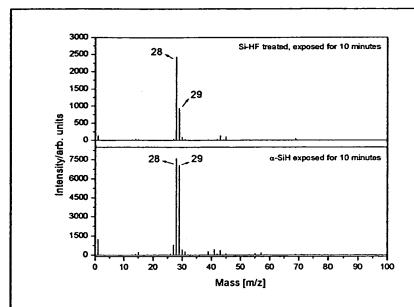


Potential Applications

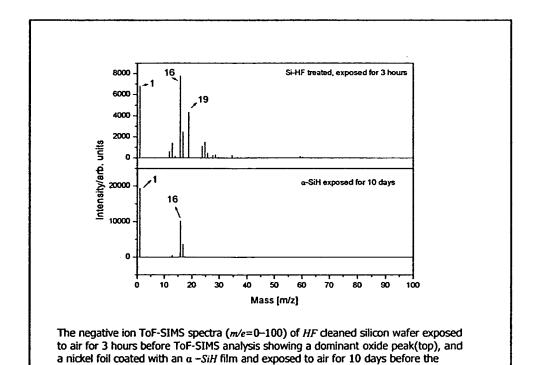
- Chemical products and processes based on hydrino-silicon chemistry, such as:
 - -hydrino-terminated silicon for chip fabrication
 - -amorphous hydrino-silicon for photovoltaics
 - -hydrino silane as precursors
 - -hydrino etching and doping processes;
- Synthesis of single crystal diamond films;
- Metal hydrides such as AuH and FeH which do not corrode to be used as anticorrosive coatings, cladding, stealth, and heat and chemical resistance;
- Light-weight, high-strength structural materials for ships and air frames;
- Ferromagnetic conductive plastics for magnetic shielding (μ-materials) in applications such as fiber optics and television tubes, storage media, generators, electric motors, sensors, actuators, computer, and electronics packaging.

Hydrino-Terminated Amorphous Silicon

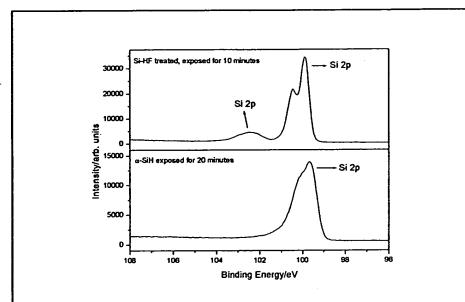
- Highly Stable in Air
- Formed by Plasma Process
- Could Eliminate HF Wet Chemistry Step
- Could Increase Chip Yield and Decrease
- Production Time
- Could Enhance Device Performance



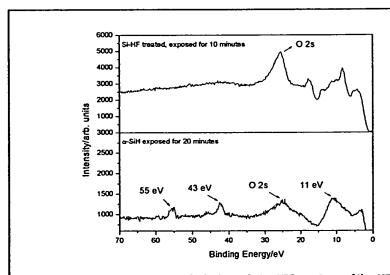
The positive ion ToF-SIMS spectra (m/e=0-100) of the HF deaned silicon wafer exposed to air for 10 min. before ToF-SIMS analysis (top), and a nickel foil coated with an α –SiH film and exposed to air for 10 min. that showed a large SiH^* peak (bottom).



ToF-SIMS analysis that retained the dominant hydride ion peak (bottom).



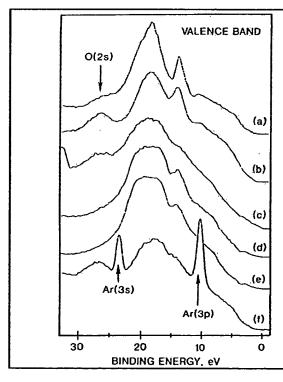
The XPS spectra (96–108 eV) in the region of the Si~2p peak of the HF deaned silicon wafer exposed to air for 10 min. before XPS analysis showing a very large SiO_x peak in the region of 101.5–104 eV (top), and a nickel foil coated with an α –SiH film and exposed to air for 20 min. before XPS analysis showing no oxide in the region of 104 eV (bottom).



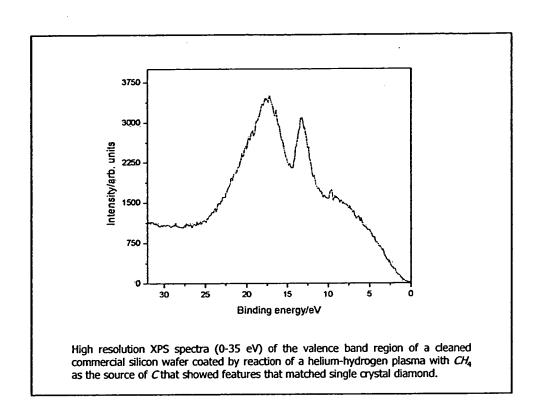
The 0–70 eV binding energy region of a high resolution XPS spectrum of the HF deaned silicon wafer exposed to air for 10 min. before XPS analysis showing only a large O 2s peak in the low binding energy region (top), and a nickel foil coated with an α –SiH film and exposed to air for 20 min. before XPS analysis (bottom). The novel peaks observed at 11, 43 and 55 eV which could not be assigned to the elements identified by their primary XPS peaks matched and were assigned to H(1/4), H(1/9), and H(1/11). The novel highly stable hydride ions formed by the catalytic reaction of He^+ and atomic hydrogen may be the basis of the extraordinary stability of the α –SiH film.

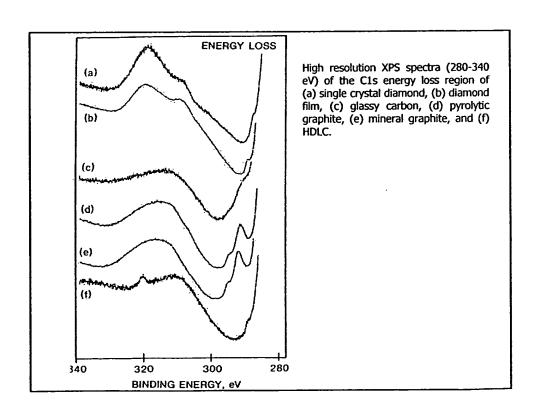
Single Crystal Diamond

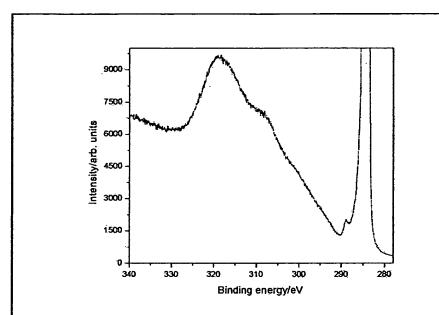
- High Deposition (20 microns/hr)
- Low Substrate Temperature (Room Temperature Possible)
- Unique Energetic Plasma
- Solid Carbon or Methane Reactant
- Without Diamond Seeding
- Very Low Power 40 W



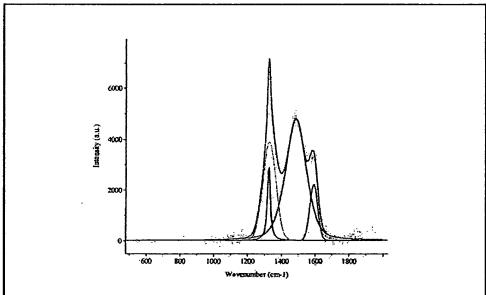
High resolution XPS spectra (0-35 eV) of the valence band region of (a) single crystal diamond, (b) diamond film, (c) glassy carbon, (d) pyrolytic graphite, (e) mineral graphite, and (f) HDLC.



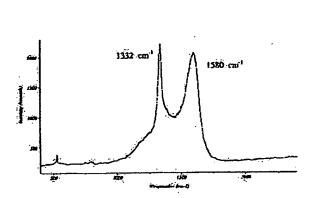




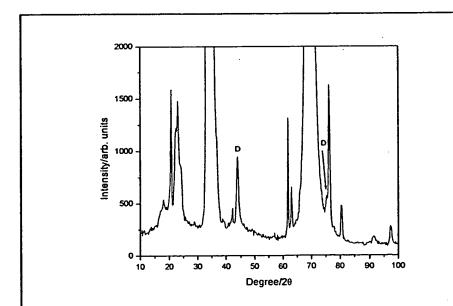
High resolution XPS spectrum (280-340 eV) of the ${\cal C}$ 1s energy loss region of a deaned commercial silicon wafer coated by reaction of a helium-hydrogen plasma with ${\cal CH}_4$ as the source of ${\cal C}$ that showed features that matched single crystal diamond.



The Raman spectrum recorded on the diamond film. The diamond band, D-band, G-band of DLC, and G-band of graphite were observed at 1323.5 cm $^{-1}$, 1327.0 cm $^{-1}$, 1484.0 cm $^{-1}$ and 1591.6 cm $^{-1}$, respectively. The 19.6 cm $^{-1}$ FWHM of the diamond peak is characteristic of and identified the film as having single crystal diamond.



The Raman spectrum of a second diamond film formed by helium-hydrogen-methane (48.2/48.2/3.6%) microwave discharge plasma CVD. A diamond band was observed at 1332 $\rm cm^{-1}$. In addition, the G-band of graphite was observed at 1580.



The X-ray Diffraction (XRD) pattern of a diamond film for $2\theta = 10^{\circ}$ to 100° . The dominant peaks were due to silicon of the substrate. Diamond peaks (D) were observed at $2\theta = 43.9^{\circ}$ (111) and 75.3° (220).

Acknowledgements



Bala Dhandapani, Director, Chemical Synthesis and **Analysis**

Ph.D. Chemical Engineering—Clarkson University, Potsdam, NY



Mark Nansteel, Director, Plasma Cell Engineering
Ph.D. Mechanical Engineering—University of California, Berkeley



Bob Mayo, Director, Plasma-to-Electric Conversion Ph.D. Nuclear Engineering—Purdue University



Paresh Ray, Research Scientist
Ph.D. Physical Chemistry - Indian Institute of Science
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Post Doc- Columbia University



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